

The AFSEM[™]

Improved Understanding of Material Behavior using Correlative In-Situ Techniques



The AFSEM concept



AFSEM correlated microscopy

AFSEM is a novel AFM platform specifically designed and developed for integration into other host systems, such as SEM or Dual-beam (SEM/FIB) microscopes. Its open design allows to simultaneously operate SEM/FIB and AFSEM inside the SEM/FIB vacuum chamber.

Main benefits:

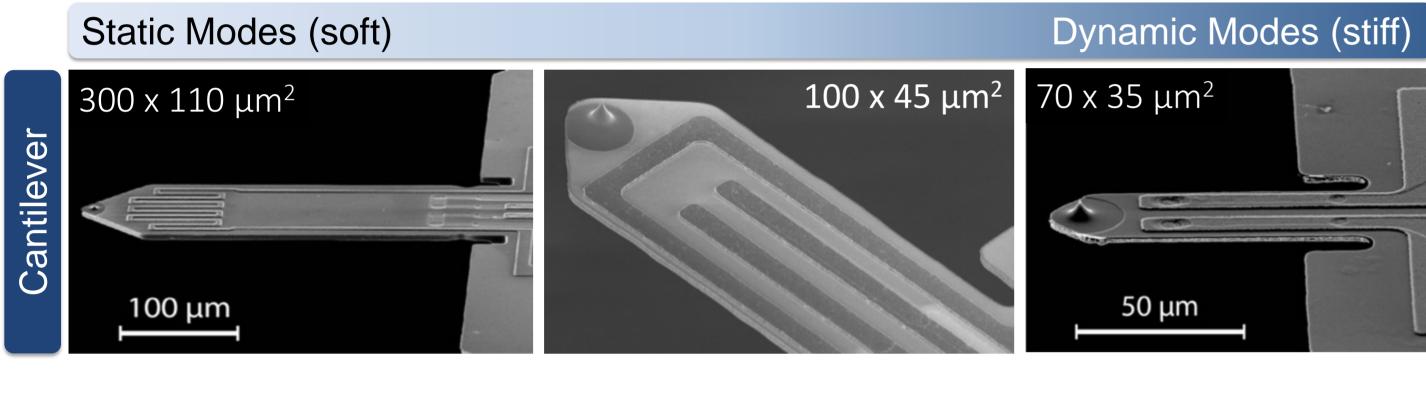
- Direct 3D information with sub-nanometer resolution
- Correlative Microscopy at highest SEM resolution of exactly the same sample position by SEM/FIB, EDX and AFSEM
- No air exposure of the sample during interactive analysis by different methods
- Nanometer Scale Analysis before SEM sample contamination
- **Ease of Use** No AFM laser alignment due to self-sensing cantilever technology



MM

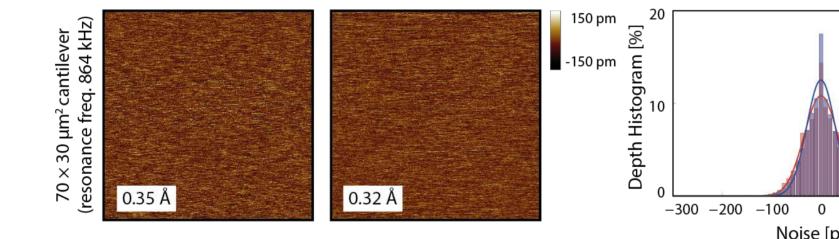
• AFSEM accepts any Sample the host system accepts

Self-Sensing Cantilever Technology





5 mm



Electrical Noise Level of 0.32 Å for Self-Sensing Cantilever equals Optical Noise Level

50 µm

 Optical Electrical

100

Noise [pm]

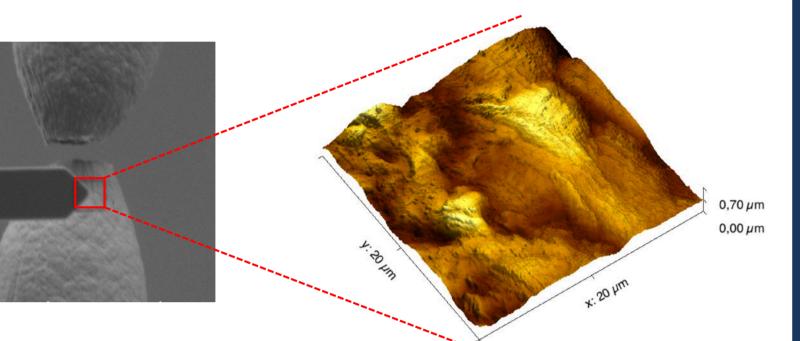
200 300

M. Dukic, J. D. Adams and G. E. Fantner. *Scientific Reports* **5**, 16393 (2015)

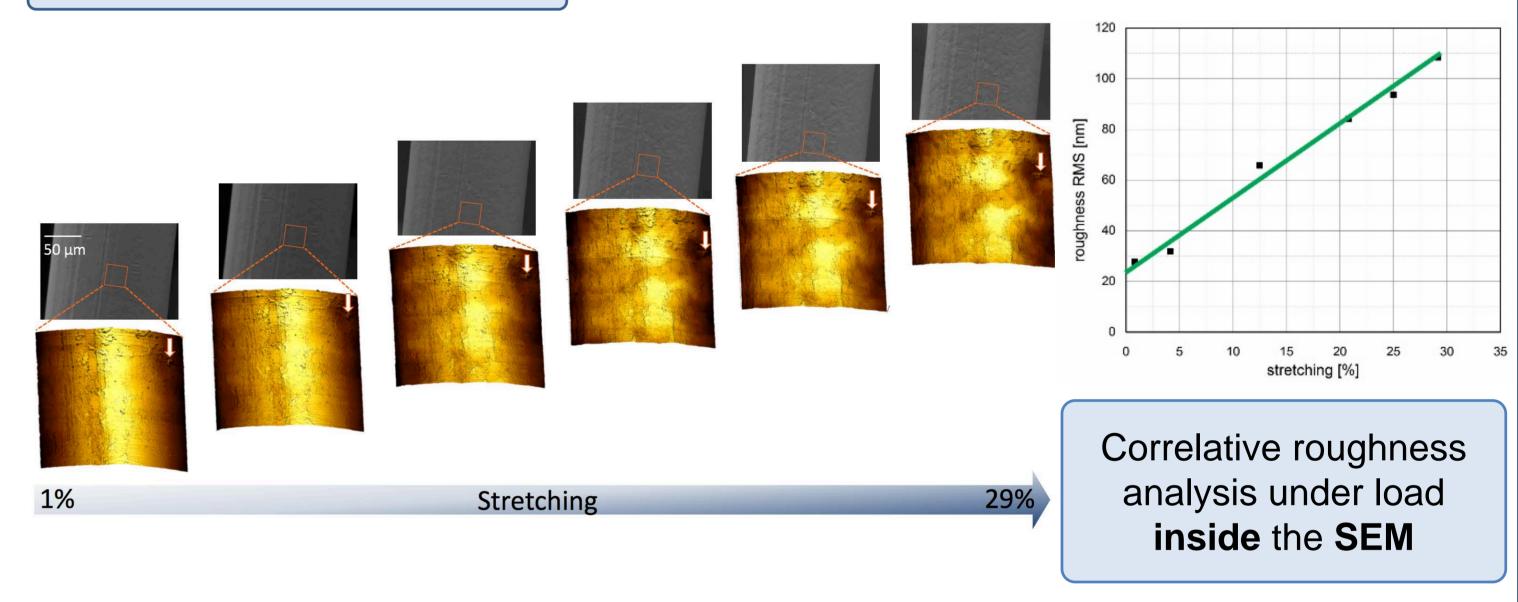
In-Situ Micro-Mechanical Testing

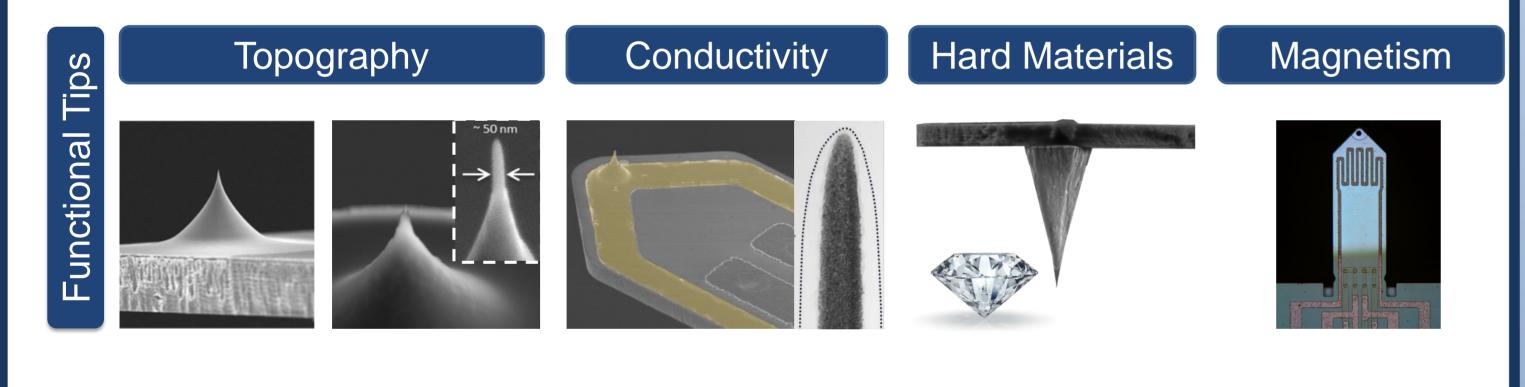


Combine **SEM**, **tensile stage** and **AFSEM**



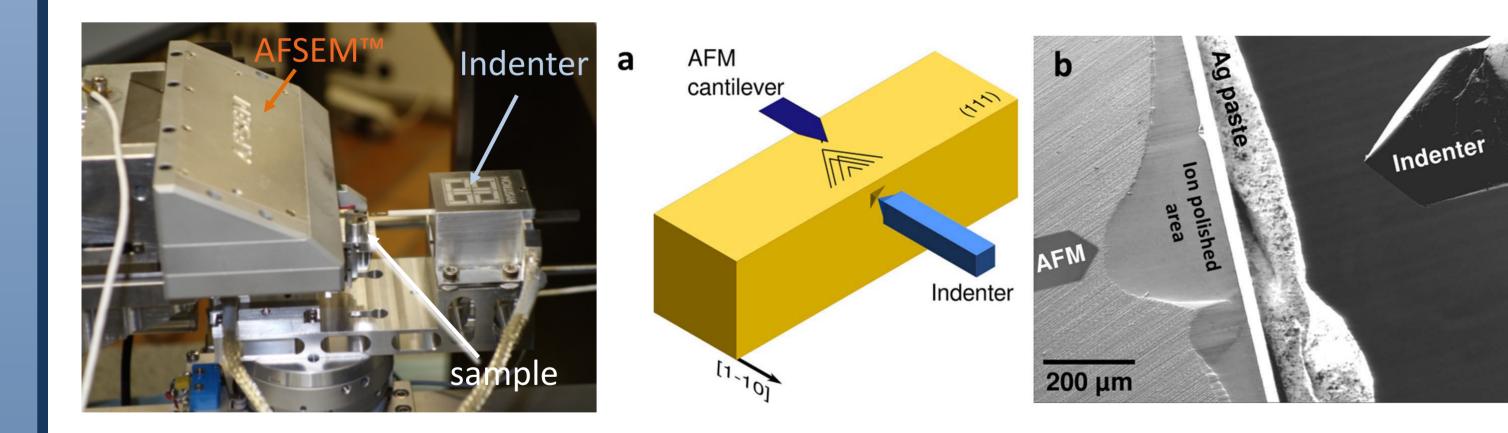
Observe sample changes with **SEM**, measure details with **AFSEM**





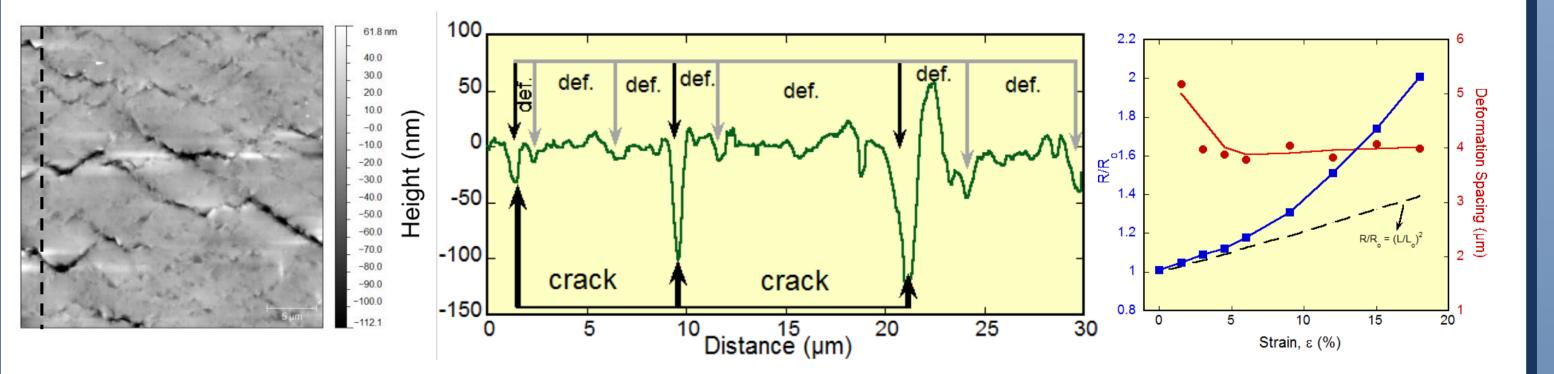
Correlative Nano-indentation Analysis

Combine SEM, nano-indentor and AFSEM for correlative in-situ experiments

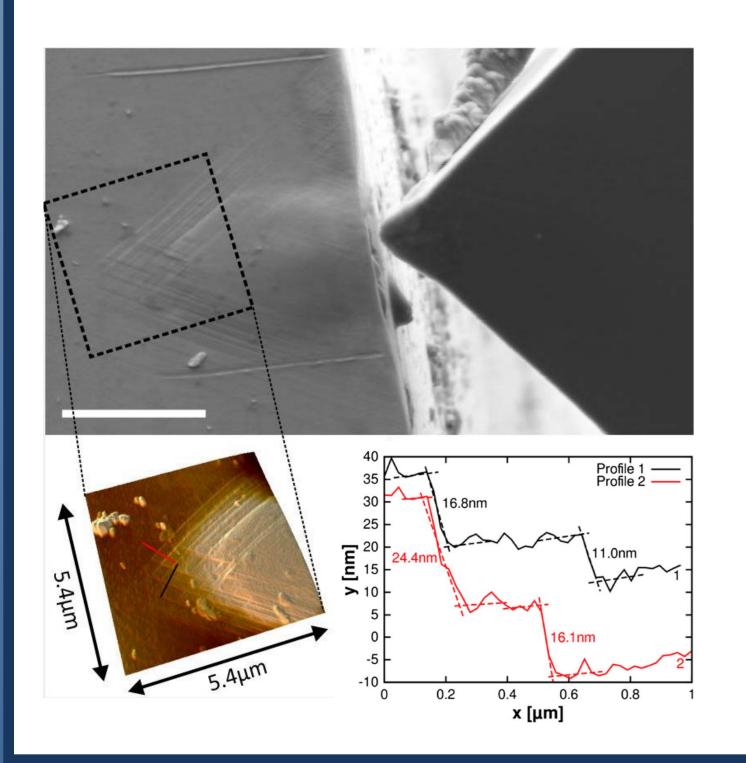


Mechanical Testing of Flexible Electronics

Combine SEM, AFM and in-situ **4-point-probe** measurements to study flexible electronics during straining

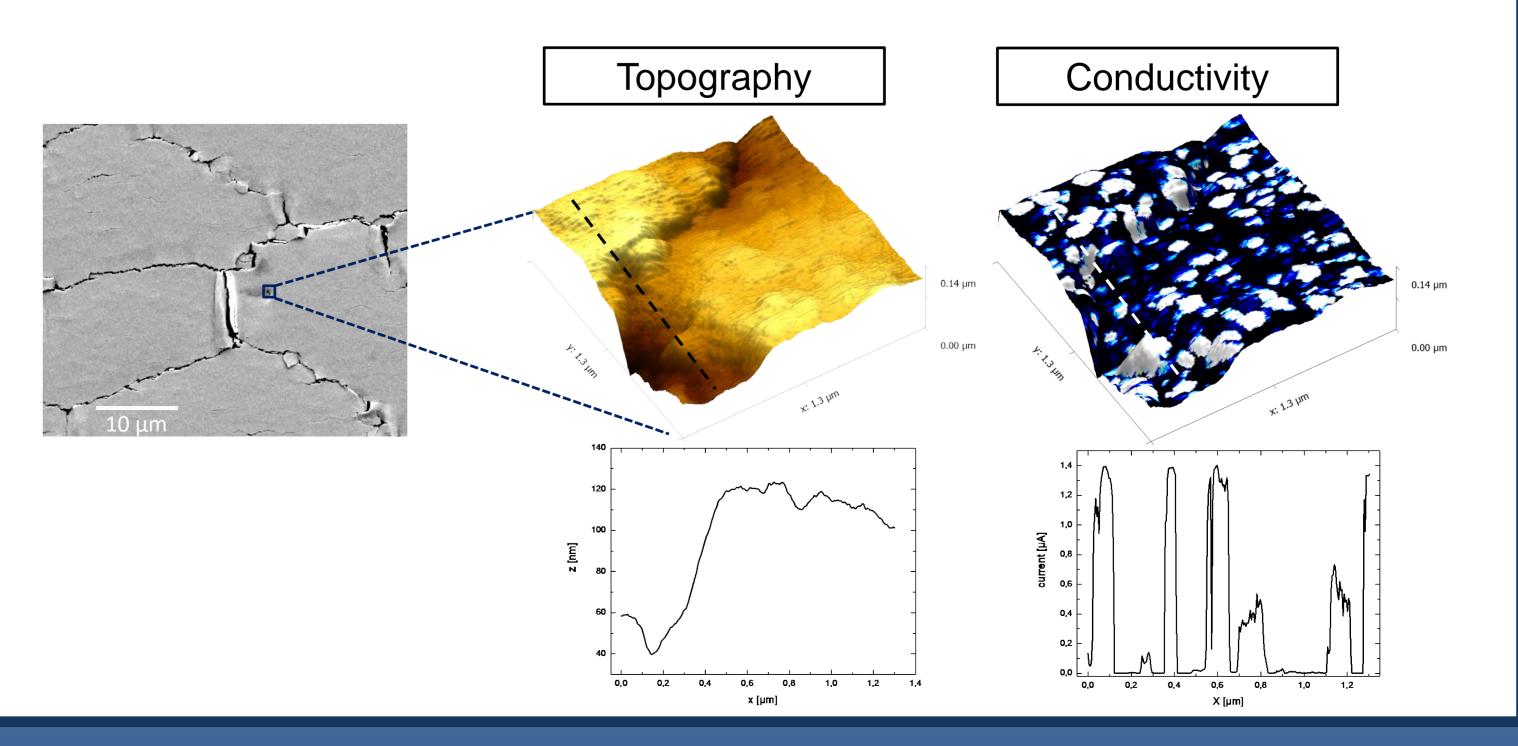


Measure in-situ 3D-topography AND conductivity



- Investigate evolution of slip-step dynamics with sub-nanometer resolution
- Analyze your sample before SEM contamination or oxidation effects
- Quantify the number of emitted dislocations exactly at the area of interest

J. Kreith et al., *Rev. Sci. Instrum.* 88, 053704 (2017)



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